AMENDMENTS TO THE CLAIMS

- 1. (Original) A method for producing single-walled carbon nanotubes, which comprises using a combination of a metal-based catalyst having a function as a catalyst for formation of graphite, and a single-crystal substrate having a certain correspondence to the metal-based catalyst with respect to the crystal grain size and the crystal orientation thereof, dispersing the metal-based catalyst on the single-crystal substrate, and feeding a carbon material to the substrate at any temperature not lower than 500°C to thereby grow single-walled carbon nanotubes through vapor phase thermal decomposition.
- 2. (Original) The method for producing single-walled carbon nanotubes as claimed in claim 1, wherein the single-crystal substrate is coated with a thin film of metal-based catalyst.
- 3. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in claim 1-or 2, wherein the thin film of metal-based catalyst has a thickness of from 0.1 to 10 nm.
- 4. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in any of claims 1 to 3claim 1, wherein the metal-based catalyst is any one or a mixture of two or more components of the group consisting of iron group metals, platinum group metals, rare earth metals, transition metals and their metal compounds.
- 5. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in any of claims 1 to 4claim 1, wherein the single-crystal substrate is formed of a substance stable at 500°C or higher.
- 6. (Original) The method for producing single-walled carbon nanotubes as claimed in claim 5, wherein the single-crystal substrate is any of sapphire (Al₂O₃), silicon (Si), SiO₂, SiC or MgO.

- 7. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in any of claims 1 to 4claim 1, wherein hydroxyapatite is used in place of the single-crystal substrate.
- 8. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in any of claims 1 to 7claim 1, wherein single-walled carbon nanotubes with controlled diameter are grown through vapor phase thermal decomposition, the diameter depending on the combination of the metal-based catalyst and the single-crystal substrate and its crystal plane.
- 9. (Original) The method for producing single-walled carbon nanotubes as claimed in claim 8, wherein the combination of the metal-based catalyst, the single-crystal substrate and the crystal plane connecting the two is a combination of Fe and any of A-plane, R-plane or C-plane of sapphire.
- 10. (Currently Amended) The method for producing single-walled carbon nanotubes as claimed in any of claims 1 to 9claim 1, wherein the carbon material is a carbon-containing substance that is gaseous at any temperature not lower than 500°C.
- 11. (Original) The method for producing single-walled carbon nanotubes as claimed in claim 10, wherein the carbon material is methane, ethylene, phenanthrene or benzene.